

<b>INFORMATION DISCLOSURE STATEMENT BY APPLICANT</b>  <i>(use as many sheets as necessary)</i>				<b>Complete if Known</b>	
				Application Number	10/719,192
				Filing Date	November 21, 2003
				First Named Inventor	Seung-Kwon Baek et al.
				Art Unit	2611
				Examiner Name	Leila Malek
Sheet	<b>B1</b>	of	<b>B1</b>	Attorney Docket Number	5649-1185

U.S. PATENT DOCUMENTS AND APPLICATIONS					
Examiner Initials*	Cite No.	Document Number	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
		Number-Kind Code (if known)			
		US-			
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FOREIGN PATENT DOCUMENTS						
Examiner Initials*	Cite No.	Foreign Patent Document	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	T
		Country Code, Number, Kind Code (if known)				
	1.	JP 2001-136149 A	05-18-2001	Nippon Telegr. & Teleph. Corp.		Abstract
	2.	JP 2001-022731 A	01-26-2001	Yamatake Corp.		Abstract
	3.	WO 02/48901 A2	06-20-2002	IHP GMBH-Innovations For High Performance Microelectronics/Institut Für Innovative Mikroelektronik (DE)		Abstract

NON PATENT LITERATURE DOCUMENTS			
Examiner Initials*	Cite No.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published	T
	4.	Japanese Office Action (2 pages) corresponding to Japanese Patent Application No. 2003-394450; Mailing Date: April 8, 2009.	No

iDoc# 773046

Examiner Signature		Date Considered	
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\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.